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Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.tandfonline.com/loi/gpss20

Synthesis and Photoisomerization Of 4,4-Diphenyl-2,6-Di(p-Methoxyphenyl)-4H-Thiopyran-1,1-Dioxide, An Approach To The Regioselectivity in Photorearrangement of 2,4,4,6-Tetraaryl-4H-Thiopyran-1,1-Dioxides

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Version of record first published: 19 Dec 2006.

To cite this article: Arash Mouradzadegun & Hooshang Pirelahi (2000): Synthesis and Photoisomerization Of 4,4-Diphenyl-2,6-Di(p-Methoxyphenyl)-4H-Thiopyran-1,1-Dioxide, An Approach To The Regioselectivity in Photorearrangement of 2,4,4,6-Tetraaryl-4H-Thiopyran-1,1-Dioxides, Phosphorus, Sulfur, and Silicon and the Related Elements, 165:1, 149-154

To link to this article: <u>http://dx.doi.org/10.1080/10426500008076333</u>

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SYNTHESIS AND PHOTOISOMERIZATION OF 4,4-DIPHENYL-2,6-DI(p-METHOXYPHENYL)-4H-THIOPYRAN-1,1-DIOXIDE, AN APPROACH TO THE REGIOSELECTIVITY IN PHOTOREARRANGEMENT OF 2,4,4,6-TETRAARYL-4H-THIOPYRAN-1,1-DIOXIDES

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(Received April 04, 2000; In final form April 27, 2000)

Synthesis and photoisomerization of the new sulfone derivative 1c is described. Upon photolysis at 254 nm the sulfone 1c, unlike those of the model compound 1b and the other 2,4,4,6-tetraarylsubstituted sulfone derivatives, undergoes rearrangement in high regioselectivity to the bicyclic photoproduct 2c. The isolation of bicyclic photoproducts 2b and 2c under our experimental conditions led us to determine the molar ratios of these species during the transformations using HPLC.

Keywords: 4H-Thiopyran-1,1-dioxide; regioselectivity; photoisomerization

INTRODUCTION

Recently, interesting photochemical behavior of 4H-thiopyrans have been studied extensively in our and other laboratories¹⁻⁶, however on sulfone derivatives these studies are limited only to 4,4-diphenyl-4H-thiopyran-1,1-dioxide and some of the tetraarylsubstituted sulfones with general structure $1^{7,8}$. Upon direct photolysis at 254 nm or sensitized (in aceton) photolysis at 350 nm the 4,4-diphenyl-4H-thiopyran-1,1-dioxide

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undergoes rearrangement to 6,6-diphenyl-2-thiabicy-1a clo[3.1.0]hexen-2,2-dioxide 2a accompanied by a solvent addition product 3-methoxy-4,4-diphenyl-2,3-dihydro-4H-thiopyran-1,1-dioxide⁷. On irradiation of some 2,4,4,6-tetraaryl-4H-thiopyran-1,1-dioxides 1 (Ar₁=C6H5, 4-CH₃C₆H₄, $4-(t-C_4H_9)C_6H_4$ $Ar_2 = C_6 H_5$, $4-FC_6H_4$ and $Ar_1=4-(t-C_4H_9)-C_6H_4$, $4-CH_3C_6H_4$, $4-FC_6H_4$, $Ar_2=C_6H_5$) with high pressure mercury lamp the corresponding 1,2,4,5-tetrasubstituted cyclopentadienes with general structure 3 were obtained as the main photoproducts through SO_2 extrusion along with the bicyclic photoproduct 2 and the other minor components⁸.



a) $Ar_1 = H$, $Ar_2 = C_0H_3$, b) $Ar_1 = Ar_2 = C_0H_3$, c) $Ar_1 = 4 - CH_3OC_0H_4$, $Ar_2 = C_0H_3$

The present study deals with the preparation and photochemistry of a new compound of general structure 1, 4,4-diphenyl-2,6-di(p-methoxyphe-nyl)-4H-thiopyran-1,1-dioxide, having electron donating groups in para positions of 2,6-diphenyl substituents. Such a model should provide further insight into the probable photochemical mechanism in comparison with the other tetraaryl analogues and also furnishes an access to a new hetero bicyclo[3.1.0] system and its chemistry.

RESULTS AND DISCUSSION

In order to study the photochemical transformation behavior of 1c in camparison with the model compound 1b, 1×10^{-3} M solutions of sulfones 1b and 1c were prepared in chloroform. Irradiation was carried out in sealed NMR tubes with a low pressure mercury lamp at $\lambda=254$ nm under an argon atmosphere at room temperature. The reactions ere followed by ¹H-NMR and the quantitative analyses were performed by HPLC at different time intervals.

In ¹H-NMR spectra, the singlets of 1b and 1c at 6.70 and 6.62 (H-3,-5) ppm gradually decreased, while two new sets of doublets appeared at 6.91. 6.77 (H-4) ppm and 3.96, 3.85 (H-5) ppm for 2b and 2c respectively, as well as at 7.33 (H-3) ppm and 5.25 (H-5) ppm for cyclopentadiene 3b, where no signals for 3c could be detected (Table I). That the corresponding cyclopentadiene as photoproduct of 1c is not formed contrasts sharply with that of the model compound 1b and the other 2,4,4,6-tetraaryl-4H-thiopyran-1,1-dioxides containing -CH₃, -F or t-C₄H₉ groups in para positions of the phenyl substituents. Considering that the excitation energy tends to localize in minimum MO energy and that the electronically excited species react by pathways to minimize energy as the reactions coordinates are traversed⁹, the resulting behavior reveal that by substitution of two electron donating methoxy groups at para positions of 2,6-phenyl substituents, the energy content of the transition state in the vinyl-vinyl di- π -methane pathway becomes lower than the phenyl-vinyl di- π -methane one and the rearrangement takes place with high regioselectivity to give solely 2c.



This result is in accordance with the well documented fundamental systems that have been shown by Zimmerman, Gravel and Leboeuf 9,7 .

		, ,						
Compound	H-3,-5	ОСНЗ	H-4	H-5	H-3	H-5		
1b	6.70							
1c	6.62	3.81						
2b			6.91_	3.96				
2c			6.77	3.85				
3b					7.33	5.25		

TABLE I The characteristic chemical shifts for 4H-thiopyran-1,1-dioxide 1b and 1c, bicyclic photoproducts 2b and 2c and cyclopentadiene 3b in chloroform-d

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We could also determine molar ratios of the bicyclic species during the reaction by the area of characteristic peaks in HPLC using the corresponding calibration curves of the isolated **2b** and **2c** (Table II). Due to the transformations of the primary bicyclic photoproducts to other unidentified products during the reaction, the isolation of **2b** and **2c** in high yields was unsuccessful.

TABLE II The yields (%) of 2b and 2c during the 90 minutes of photoisomerization under identical experimental conditions. The values are an average of three runs measured by the area of HPLC characteristic peaks in the reaction mixtures

Compound	Time(min), chlorofom									
	5	10	15	20	30	45	60	90		
	2b ^a	27	25	15	11	9	3	0	0	
	2c ^b	29	25	12.5	9.8	8	4.5	2	0	

a. The retention time of 2b was 4.5 min in a mixture of methanol-water(78:22).

b. The retention time of 2c was 4.15 min in a mixture of methanol-water(80:20).

EXPERIMENTAL

Melting points were determined on a Gallenkamp melting point apparatus. UV and visible spectra were determined on Shimadzu 265-FW spectrophotometer. Infrared spectra were measured in KBr with Shimadzu 4300 FT-IR. The reaction was followed by HPLC using a SGX C18 column in the methanol-water system. NMR spectra ere recorded with Bruker AC-80 spectrometer; tetramethylsilane served as an internal standard. All photolyses were carried out using a low pressure mercury lamp.

Syntheses

4H-Thiopyran-1,1-dioxide 1c was synthesized from the reaction of the corresponding 4H-thiopyran (1 mmole) with hydrogen peroxide 30% (1.6 mmole) in hot acetic acid (20 ml). The reaction mixture kept at 120°C until the transitionally formed 4H-thiopyran-1-oxide disappeared (the reaction followed by tlc), then it was cooled and poured on ice (40g). White precipitate was collected and recrystallized from ethanol to give 1c

(90%). The model compound 1b was synthesized by the method perviously described⁸.

4,4-Diphenyl-2,6-di(p-methoxyphenyl)-4H-thiopyran-1,1-dioxide(1c)

Colorless crystals, m.p.: 198–199°C (from EtOH); UV: λ max (MeOH) nm (loge) 265 (3.26); IR: 1128 and 1290 cm⁻¹ (SO₂); ¹H-NMR, (CDCl₃) δ : 3.81 (3H,s,OMe), 6.62 (2H,s,H-3,5), 6.86–7.61 (18H,m,Ar₁,Ar₂).

General procedure for photolysis

 1×10^{-3} M solutions of sulfones **1b** and **1c** were prepared in chloroform-d₁ in NMR tubes then degassed and sealed under an argon atmosphere. Irradiation was carried out with a low pressure mercury lamp using a monochromatic UV light with λ =254 nm at room temperature. The progress of the photochemical reaction was followed by ¹H-NMR and HPLC at different time intervals.

Photoproducts

In contrast to the model compound **1b** which converted to the main photoproduct 1,2,4,5-tetraphenylcyclopentadiene along with **2b** and the other minor photoproducts⁸, irradiation of **1c** gave the regioselective bicyclic compound **2c** as the main photoproduct which was isolated by chromatography and recrystallized from ethanol.

1,3-Di(p-methoxyphenyl)-6,6-diphenyl-2-thiobicyclo[3.1.0]hexen-2,2-dioxide(2c)

Colorless crystals, m.p.: 225–226°C: UV: λ max (MeOH) nm (loge) 290 (3.39). 225 (3.97); IR: 1138 and 1296 cm⁻¹ (SO₂); ¹H-NMR (CDCl₃), δ : 3.74 (3H,s,OCH₃), 3.85 (1H,d,H-5), 6.77 (1H,d,H-4), 6.70–7.54 (18H,m,Ar₁,Ar₂).

Acknowledgements

Support of this investigation by the Research Council at the University of Tehran through Grant No. 372/1/514 is gratefully acknowledged.

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